Enhancing Efficiency and Stability of Hot Casting p–i–n Perovskite Solar Cell via Dipolar Ion Passivation

Kai-Chi Hsiao,†‡ Meng-Huan Jao,† Bo-Ting Li,† Ting-Han Lin,§ Stan Hsueh-Chung Liao,‖ Ming-Chung Wu,§⊥∥§ and Wei-Fang Su⊥§⊥†⊥

†Department of Materials Science and Engineering, National Taiwan University, Taipei City 10617, Taiwan
‡Department of Materials Science and Engineering, Advanced Research Center for Green Materials Science and Technology, National Taiwan University, Taipei City 10617, Taiwan
§Department of Chemical and Materials Engineering, Chang Gung University, Taoyuan City 33302, Taiwan
‖FrontMaterials Corporation Ltd., Taipei City 10087, Taiwan
¶Green Technology Research Center, Chang Gung University, Taoyuan City 33302, Taiwan
⊥Division of Paediatrics Neonatology, Department of Paediatrics, Chang Gung Memorial Hospital, Taoyuan City 33305, Taiwan

Supporting Information

ABSTRACT: Anionic and cationic defects are considered as one of the crucial factors that affect carrier transport property and degradation of perovskite photovoltaic materials. Herein, we demonstrate a simple passivation of hot casted perovskite film in air by a dipolar ion, 2-thiophene ethylammonium chloride (TEACl), showing enhanced power conversion efficiency (PCE) of solar cell from 15.44% to 18.84% with increased open circuit voltage (V\text{oc}) by 50 mV. The dipolar ion of TEACl can simultaneously passivate both cationic and anionic defects. Space charge limited current (SCLC) model, Urbach energy analysis, and photoluminescence spectroscopy were conducted and revealed that the defects passivated by TEACl reduced the defects density of perovskite films, nonradiative recombination, and electronic disorder. In addition, the device with TEACl passivation exhibited outstanding stability of power output (<0.1% decay) as compared with the device without passivation (>8% decay) from the 300 s measurement of current versus time plots (J–T plots) at 65% relative humidity and 50 °C in air. The 80% of initial PCE was maintained after 700 h storage. As compared to conventional passivation approaches which are typically carried out at complicated crystallization step of perovskite, this post-treatment process can be easily done on the crystallized perovskite film. This facile approach is upscale and compatible with conventional coating techniques such as slot-die coating, spray, etc. for high-quality perovskite film.

KEYWORDS: perovskite, solar cell, hot casting, dipolar ion, solution process, passivation, stability

1. INTRODUCTION

The organic–inorganic hybrid perovskite (OIH P) photovoltaic has drawn lots of attention since its first debut in 2009. The unique properties of OIH P such as high absorption coefficient in the visible light region, a relatively low exciton binding energy, and long carrier lifetime make it a potential candidate for the next generation photovoltaic technology. In the OIH P photovoltaic, there are two types of device architectures including conventional (n–i–p) and inverted (p–i–n) architectures. The n–i–p architecture means the device is assembled in the order of electron transport layer/perovskite active layer/hole transport layer, whereas the p–i–n architecture is assembled in the reserved order. For our work, we adapted the p–i–n architecture because of the ease of device fabrication, low temperature process (150 °C), and no hysteresis issue of device performance.

Nowadays, many research groups are improving the power conversion efficiency (PCE) of OIH P devices and anticipate bringing this technology into industry. Over the past decade, the PCE of perovskite solar cell has been increased from 3.8% in 2009 to 23.3% in 2018, which is among the best performance obtained by thin film photovoltaics and is comparable to the well-developed Si solar cells. Up to now, for most high efficiency OIH P photovoltaics, the light absorbing active perovskite layer is deposited based on solvent engineering strategy, which creates a smooth and compact thin film by using antisolvent during the spin coating process. However, the complexity of solvent dripping procedure, the requirement of critical drip timing, and the excessive use of antisolvent limit the...
potential of upscale manufacture by this process. With the hot casting process, highly crystalline perovskite thin film can be formed within a few seconds by depositing precursor solution on heated substrate in air. The hot casted perovskite film exhibits high device performance. The process is promising for scaling up from lab-scale small area to industry-scale large area module.14

The hot casting process can deliver large grain size and high crystalline perovskite thin film for high efficiency solar cell due to the fast evaporation of solvent on heated substrate.13,15,16 Several research groups are dedicated to exploring the growth kinetics of perovskite thin film made by hot casting process and anticipate unveiling the relationship between crystallinity and device performance.15,17 Nevertheless, the study of hot-casting-derived perovskite thin film mostly focused on increasing crystallinity or enlarging crystal size, while it is imperative to delicately passivate perovskite thin films to realize high efficiency and stable devices.

Despite the high crystallinity of silicon solar cell, the dangling bond at the surface of silicon is still regarded as a detrimental issue for deteriorating the device performance.1,8,19 To annihilate dangling bond as well as increase PCE, surface passivation is a common approach in silicon solar cell, while in OIHP thin film, the uncoordinated lead (Pb2+) and halide (X−) induce positive and negative charge defects. Therefore, various molecules such as electron-donating Lewis base or electron-accepting Lewis acid were used to passivate the ionic defects in OIHP. The Lewis base molecules are good candidates, e.g., thiophene and pyridine, for surface passivation and trap state reduction of perovskite thin film due to their donor-like behaviors,20−22 whereas the Lewis acid molecule, e.g., phenyl C61 butyric acid methyl ester (PC61BM), acts as electron acceptor to passivate the uncoordinated halide induced deep trap state.23 Additionally, the halide vacancies tend to degrade perovskite materials, in which the oxygen can be trapped in the halide vacancies to induce superoxide radical under illumination.24 As a result, the photoinduced radicals degrade the perovskite into small volatile molecules.25 Therefore, the passivation of the relevant defect-induced trap state in OIHP thin film is an effective method to improve PCE as well as the stability of OIHP solar cell.26

However, few of these molecules have the ability to simultaneously passivate both cationic and anionic defects in OIHP and most of these passivation approaches aim at OIHP thin film made from a complicate and difficult control antisolvent deposition during the crystallization step.27−31 As a result, the corresponding passivation engineering with potential to large scale fabricated OIHP will be an issue.

Here in this work, we demonstrate a simple dipolar ion post treatment approach for hot casted perovskite film, which can simultaneously passivate cationic and anionic defects and improve the carrier mobility, thus enhancing the efficiency and stability of p-i-n planar solar cell. Among evaluated dipolar ions, 2-thiophene ethylammonium chloride (TEACl) shows enhanced power conversion efficiency (PCE) of solar cell from 15.44% to 18.84% and over 80% of initial PCE is maintained after 700 h storage. Spectroscopy, electronic, and device characterizations were systematically investigated to show the effective suppression of nonradiative recombination in perovskite film after the treatment of TEACl.

2. EXPERIMENTAL SECTION

Material Synthesis. For dipolar ions synthesis, 2-thiophene ethylammonium iodide, bromide, and chloride were synthesized by reacting with equal molar 2-thiophene ethylamine (Tokyo Chemical Industry Co., Ltd. 98%) and hydroiodic acid (Acros, 57% HI in ethanol), hydrobromic acid (Acros, 33% HBr in acetic acid), hydrochloric acid (Fisher, 36% in H2O), respectively. Take TEACL for example, the equal molar 2-thiophene ethylamine and hydroiodic acid were first transferred into a three-neck flask. After vigorous stirring of the mixture for 2 h in an ice bath, the solvent was removed by a rotary evaporator to obtain a pale yellow powder. The powder was washed with diethyl ether (Fisher, 99%) until the color turned white. The white powder was further purified by recrystallization using anhydrous ethanol (Sigma-Aldrich, 99.5%). Subsequently, the white disk-like powder was dried in a vacuum oven at 70 °C overnight and stored in nitrogen filled glovebox.

Device Fabrication. The deposition protocol of p-i-n hot casted perovskite device was followed by the previous work in literature.1 The fluoride-doped tin oxide (FTO)−coated glass substrates (Pilkington, 7 Ω/sq) were cleaned in the order of DI water, base solution, methanol, and isopropanol in ultrasonic bath for 15 min. Prior to the deposition of the hole transport layer, the UV−ozone treatment was carried out to again clean the FTO substrate. The hydrophilic substrate surface helps the MAPI3 perovskite solution was prepared by dissolving lead iodide (Alfa Aesar, 99.9985%) and methylammonium iodide (FrontMaterials Co. Ltd.) in equal stoichiometric mole in a cosolvent system of dimethyl sulfoxide (Acros, 99.7%) and γ-butyrolactone (Acros, 99+/%) in 3:7 volume ratio. The mixture was stirred for 12 h at 70 °C before using. For perovskite film deposition, the as-prepared substrates (FTO/ NiO) and precursor solution were preheated at 150 and 70 °C on the hot plate, respectively, for 10 min to reach thermal equilibrium. Around 50 μL of perovskite precursor solution was quickly dropped onto the hot substrate followed by spin coating at 4000 rpm for 30 s. The transparent yellow perovskite precursor became a black solid film in the beginning of the spin coating procedure that indicated the precursor turn to crystallized perovskite film immediately. For passivating the perovskite film, the passivation molecules, which were TEACL, TEABr, and TEAIE, at 1−20 mM in isopropanol were preheated at 70 °C and then spin-coated on the top of crystallized perovskite film at 3000 rpm for 20 s. Prior to capping electron transport layer, here it was PC71BM, the baking step (70 °C for 15 min) was carried out to remove residual solvent (IPA). Subsequently, 20 μg/mL PC71BM (FrontMaterials Co. Ltd. 99%) in chlorobenzene was spin-coated on passivated perovskite film at 1000 rpm for 30 s, whereas for the devices without passivation, the PC71BM was directly deposited on the crystallized perovskite film. Then, the work function modifier polyethylenimine (PEI) of 0.1 wt % dissolved in isopropanol was eventually spin-coated onto the electron transport layer at 4000 rpm for 30 s. The device was completed by the thermal evaporation of 100 nm silver electrode with an active area of 0.09 cm2. For the results of device performance, they were summarized from the measurements of 24 devices made from 4 different batches. The electron-only and hole-only devices for space charge limited current (SCLC) model fitting were fabricated with the structure of FTO/compact TiO2/perovskite with or without passivation/PC71BM/PEI/Au and FTO/NIO/perovskite with or without passivation/Au, respectively.

Characterization of Materials and Devices. The curves of photocurrent density (J)−voltage (V) of solar cell devices were measured in air under A.M. 1.5 irradiation (100 mW/cm2) of a solar simulator source (YAMASHITA DENO, YSS-200A, class AAA) equipped with a 1600 W xenon short arc lamp and a Keithley 2400 source meter. For each run of the test, the light intensity was calibrated with a monocrystalline silicon standard cell having KG-5 filter to adjust mismatched spectra to unity. The J−V curves of devices with 0.09 cm2 active area were obtained from both forward (from −0.2 to 1.2 V) and backward (from 1.2 to −0.2 V) scans. The step voltage of the test was fixed at 40 mV, and the delay time was fixed at 10 ms. Absorption spectra of the films were measured using a UV−vis spectrometer.
(Hitachi, U-4100). To observe Urbach tail of perovskite films, the sensitive measurement using an integrating sphere to circumvent the light scattering from thin films was employed. The Urbach tail energy ($E_u$) calculation was followed with $\alpha = \alpha_0 \exp(h\nu/E_u)$. As we take the logarithm of this equation, the equation becomes $\ln(\alpha) = \ln(\alpha_0) + (h\nu/E_u)$. The term of $(h\nu/E_u)$ can be obtained from the slope of the straight line of plotting $\ln(\alpha)$ against the incident photon energy ($h\nu$). Finally, the Urbach energy ($E_u$) can be obtained from the reciprocal of the fitting slope, which is detailed in the main text of this paper. Steady-state photoluminescence (PL), continuous-wave PL, and time-resolved PL (TRPL) were performed by exciting samples with a 440 nm continuous-wave diode laser (DONGWOO, PDLH-440-25). The transient TRPL was recorded by a time-correlated single photon counting (TCSPC) (WELLS-001 FX, DONGWOO OPTRON) spectrometer at a 312.5 MHz frequency with 2 ms duration. Electrochemical impedance spectroscopy (EIS) measurement was done by using impedance measurement unit (ZAHNER, elektrik PP210) under 1 sun illumination (100 mW/cm²) with the same solar simulator as described before. The applied direct current (dc) voltage was fixed at 1.05 V for devices with FTO/NiO/perovskite with or without passivation/PC$_{61}$BM/PEI/Au with a 10 mV perturbation alternating current (ac). The frequency ranging from 10 kHz to 0.1 Hz was used. Cross-sectional FE-SEM samples were prepared from the actual device by mechanical glass cutter. The SEM images of devices were acquired by a field emission scanning electron microscope (Hitachi, SU8000, voltage 10 kV, working distance 8.0 mm). X-ray diffraction (XRD) patterns were obtained using high power (18 kW) X-ray diffractometer (Rigaku TTRAX 3) under Cu K$_\alpha$ radiation ($\lambda = 1.5406$ Å). The grazing-incidence wide-angle X-ray scattering (GIWAXS) spectra of samples were obtained using synchrotron X-ray scattering ($\lambda=1.239810$ Å) at BL23A1 SWAXS end station of the National Synchrotron Radiation Research Center (NSRRC) in Hsinchu, Taiwan. The trap density and carrier mobility were calculated by using the space charge limited current (SCLC) model. For electron-only device, the architecture was FTO/TiO$_2$/MAPbI$_3$ with and without passivation/PC$_{61}$BM/PEI/Au, whereas for hole-only device, the architecture was FTO/NiO/perovskite with and without passivation/Au. The $I$–$V$ curve for the SCLC model fitting was measured in the dark from 0 to 3 V for electron-only device and from 0 to 5 V for hole-only device with a scan rate of 10 ms. The surface potential difference, the samples were mapped in the dark or under $\lambda = 550$ nm LED light source (WLS-LED, Mightex) illumination at an angle of around 45°.

### 3. RESULTS AND DISCUSSION

The properties of perovskite can be manipulated with different stoichiometry of ammonium salt and lead halide because of the different contribution of p orbital of lead from lead iodide and of p orbital of halide from ammonium salt. The slight over ratio of ammonium salt or lead halide can facilitate the carrier transportation and improve the imbalance of carrier transfer rate due to a slight band shift of perovskite, which is closed to p-type or n-type property. To maintain the ambipolar properties of perovskite thin films, the hot casting starts with stoichiometric amount of methylammonium iodide and lead iodide. Briefly, for hot casting perovskite films, the as-prepared substrates (FTO/ NiO) and precursor solution (methylammonium lead triiodide, CH$_3$NH$_3$PbI$_3$) were preheated at 150 and 70 °C on the hot plate, respectively. Around 50 μL of perovskite precursor solution was quickly dropped onto the hot substrate followed by spin coating at 4000 rpm for 15 s. The crystallized perovskite films was formed immediately (details in the Experimental Section). The organoammonium iodide dipolar ion will be a good candidate to passivate both cation and anion defects present in perovskite film. Three organoammonium iodide dipolar ions were selected as passivation molecules: methylammonium iodide (MAI), phenylethylammonium iodide (PEAI), and 2-thiophene ethylammonium iodide (TEAI). Their chemical structures are shown in Figure 1. In order to dissolve the dipolar ions such as MAI, PEAI, and TEAI, one should use polar solvent such as methanol (MeOH), ethanol (EtOH), or isopropyl alcohol (IPA). However, the content of active hydrogen is high for MeOH (3.12 atom %) and EtOH (2.17 atom %) as compared with IPA (1.67 atom %). The active hydrogen of MeOH and EtOH quickly reacted with crystallized perovskite to form volatile methylamine (MA), hydroiodic acid (HI), and lead iodide (PbI$_2$), as shown in Figure S1a. Thus, the IPA was used as the solvent to dissolve dipolar ions. Various concentrations of IPA solutions (1–20 mM) of dipolar ions

### Table 1. Photovoltaic Performance of Perovskite Solar Cells with/without Passivation Molecules

<table>
<thead>
<tr>
<th>Sample</th>
<th>$V_{oc}$ (V)</th>
<th>$J_{sc}$ (mA/cm$^2$)</th>
<th>FF (%)</th>
<th>PCE (%)</th>
</tr>
</thead>
<tbody>
<tr>
<td>W/O passivation</td>
<td>1.05 ± 0.01</td>
<td>19.39 ± 0.48</td>
<td>73.26 ± 1.19</td>
<td>14.08 ± 0.26</td>
</tr>
<tr>
<td>W/IPA</td>
<td>0.92 ± 0.03</td>
<td>16.4 ± 0.86</td>
<td>50.88 ± 4.02</td>
<td>7.69 ± 0.41</td>
</tr>
<tr>
<td>W/MAI</td>
<td>0.94 ± 0.03</td>
<td>16.54 ± 0.67</td>
<td>56.40 ± 2.70</td>
<td>8.76 ± 0.79</td>
</tr>
<tr>
<td>W/PEAI</td>
<td>1.09 ± 0.00</td>
<td>18.08 ± 0.50</td>
<td>73.59 ± 1.68</td>
<td>14.50 ± 0.31</td>
</tr>
<tr>
<td>W/TEAI</td>
<td>1.09 ± 0.01</td>
<td>19.20 ± 0.38</td>
<td>74.03 ± 1.15</td>
<td>15.49 ± 0.38</td>
</tr>
</tbody>
</table>

ACS Applied Energy Materials
were prepared and used to treat the hot-casted perovskite thin films. The optimal concentration of dipolar ions in IPA is determined to be 2.5 mM. Despite minor changes observed in the film treated with IPA, it is still a good solvent for dipolar ions. Therefore, we used the film treated with pristine IPA as a control to figure out its effect on the device performance. Table 1 summarizes the device performance with and without dipolar ion passivation. Although the perovskite film did not change much in appearance after the IPA or MAI/IPA treatment, the PCE of the device was reduced greatly from 14.08% to 7.69% and 8.76%, respectively. The passivation effect is observed for PEAI/IPA and TEAI/IPA treatment, and the PCE is increased to 14.50% and 15.49%, respectively.

To take a close look at the changes of perovskite films after each treatment, X-ray diffraction analyses were performed. It is interesting to note that the presence of dipolar ions in the IPA greatly retarded the activity of active hydrogen IPA owing to the salt effect. The peak of PbI$_2$ at around 12.5° can be clearly recognized from XRD pattern of perovskite films when they were treated with either IPA or MAI/IPA. On the other hand, the characteristic peak of PbI$_2$ cannot be observed from the films treated with either PEAI/IPA or TEAI/IPA as shown in Figure S1b of Supporting Information. The results indicate that the volatile and small size of MAI is not an effective passivation agent, and the compound decomposed into MA, HI, and PbI$_2$ during the post-annealing of the treated film at 70 °C for 15 min. However, the extent of decomposition was less than that of pure IPA treatment. The presence of PbI$_2$ in decomposed perovskite disturbed ambipolar properties of perovskite thin film, thus decreasing the device performance. While the perovskite films with PEAI and TEAI passivation showed similar appearance as the pristine perovskite film. For target devices, both PEAI and TEAI can passivate perovskite film and improve device performance. We speculate that both molecules contain aromatic structure, which is larger than methyl group of MAI, can stabilize the cation, and is less mobile than MAI. Thus, they can stay in place to passivate the defects to have high device performance. Moreover, the TEAI exhibited better device performance than PEAI because TEAI contains unshared electron of thio atom that can passivate better than PEAI. The results can also be explained from their pK$_a$ of dipolar ions (MAI = 10.64, PEAI = 9.83, and TEAI = 9.74). The small pK$_a$ of TEAI provides more dissociated cations so that it can passivate the defects more efficiently.

Both anion (I$^-$) and cation (Pb$^+$) defects in perovskite need to be passivated. Thus, the choice of the anion in the passivation molecule is of equal importance as that of the cation. We fixed cation using TEA, then explored the role of different anions (their chemical structures are shown in Figure 1). The results are summarized in Table 2. The concentration of each passivation molecules was optimized (see Table S1 in Supporting Information). The device reaches the highest PCE of 18.84% by using chloride anion as compared to the other halide passivation molecules. The Cl$^-$ is the smallest anion and exhibits the strongest electron affinity. In addition, the Pb–Cl bond has been reported to show stronger bonding than the Pb–I bond. Therefore, as compared with other anions, the Cl$^-$ anion can easily diffuse into perovskite and effectively bond with Pb ion. It implies that using passivation molecules containing Cl$^-$ can facilitate not only the fast dissociation of organoammonium halide, e.g., TEACl, but also ease of diffusion into the perovskite film to compensate the positively charged anion defect (I$^-$ vacancy).

In order to further investigate the effects of dipolar ion TEA halide in the post-treatment, characterizations using crystallography and spectroscopy were carried out. Figure S2a shows the 0–2θ X-ray diffraction pattern of perovskite films with and without passivation. The diffraction peak at 13.8° and 19.7° can be indexed to be (110) and (200) of tetragonal phase MAPbI$_3$. The absence of PbI$_2$ peak at 12.7° indicates the perovskite precursor transferred to perovskite crystal using hot-casting process. To further gain insight into the changes of
crystallization behavior, grazing-incidence wide-angle X-ray scattering (GIWAXS) was conducted. Figure S2b is the integrated 1D patterns of perovskite films from the GIWAXS measurement. For overall integration of the GIWAXS pattern, only two characteristic peaks at $Q = 10.2 \text{ nm}^{-1}$ and $14.5 \text{ nm}^{-1}$, which can be referred as (110) and (200), were identified in $Q$ range between 6−16 nm$^{-1}$. The absence of diffraction signal in $Q$ range lower than 10 nm$^{-1}$ implies that the TEA halides do play passivation role instead of the formation of low dimensional structured perovskite.

Figure 3. Effects of dipolar ions passivation on the photoluminescence profiles of perovskite film: (a) photoluminescence (PL) spectra, (b) time-resolved photoluminescence (TR-PL) profiles, continuous PL spectra of perovskite films (c) without and (d) with TEACl, (e) with TEABr, and (f) with TEAI passivation ((a)−(f) are the characteristics of perovskite films), and (g) PL spectra and (h) TR-PL profiles of perovskite films containing electron and hole transport layer.
From Table 2, we observe the enhanced device PCE by using TEA halide passivation, which is mainly resulted from the improvement of \( V_{oc} \). Usually, the improvement of \( V_{oc} \) is from the enlargement of bandgap from the addition of ions into lattice structure or the formation of low dimensional structure of perovskite.\(^{39–41}\) However, the XRD (Figure S2) and UV–vis (Figure 2) spectral analyses reveal negligible enlargement of the bandgap. Therefore, we deduce that the increased \( V_{oc} \) originated from the improved quality of perovskite thin film by treating it with TEA halide. To evaluate the inherent electronic properties of perovskite film with and without passivation, Urbach energy \( (E_u) \) was employed to estimate the energetic disorder of the films. The Urbach equation is given in the following:

\[
\alpha = \alpha_0 \exp\left(\frac{E}{E_u}\right)
\]

Here, \( \alpha \) represents the absorption coefficient of perovskite, \( E \) is the photon energy, and \( E_u \) is the Urbach energy. The calculated \( E_u \) of perovskite film without and with TEACl, TEABr, TEAI passivation from Figure 2b are 24.95, 22.65, 23.45, and 22.95 meV, respectively. The TEACl has the lowest \( E_u \) of 22.65 meV that indicates the least amount of defect states is present in the bandgap.

To probe the photogenerated carrier dynamics in the perovskite films, photoluminescence (PL) measurements were performed in air at room temperature. The PL spectra, continuous PL spectra, and time-resolved PL (TRPL) spectra of the films with and without passivation are shown in Figure 3. The films with passivation exhibit stronger steady-state PL intensity than perovskite without passivation as depicted in Figure 3a. The predominant photogenerated carriers in the perovskite are free electrons and holes because of the weak exciton binding energy.\(^{42}\) The recombination rate of free carriers can be obtained from the TRPL spectra of perovskite films as shown in Figure 3b. The average lifetime \( (\tau_{avg}) \) of charge carriers can be calculated according to the following equation, and the results are summarized in Table 3.

\[
\tau_{avg} = \frac{A_1\tau_1 + A_2\tau_2}{A_1 + A_2}
\]

<table>
<thead>
<tr>
<th>sample</th>
<th>carrier lifetime (ns)</th>
</tr>
</thead>
<tbody>
<tr>
<td>without passivation</td>
<td>53.46</td>
</tr>
<tr>
<td>W/TEACl</td>
<td>109.21</td>
</tr>
<tr>
<td>W/TEABr</td>
<td>76.87</td>
</tr>
<tr>
<td>W/TEAI</td>
<td>78.19</td>
</tr>
</tbody>
</table>

The carrier lifetime of perovskite films with passivation is longer than the film without passivation because of fewer defects and nonradiative recombination. The increased carrier lifetime confirms that the passivation can inhibit the presence of carrier scavengers from ionic defects. Among the passivation molecules, TEACl passivation exhibits the best and the longest average carrier lifetime of 109.21 ns.

The ionic defects, especially anion defects, of perovskite thin films provide a pathway for fast oxygen diffusion as the perovskite solar cell operated in ambient air.\(^{43,26,44}\) With the presence of light, the oxygen molecules occupying halide vacancies act as electron scavengers. The electrons generated from perovskite directly react with oxygen and form superoxide radicals. The superoxide radicals adversely affect the stability of perovskite due to its strong oxidation ability. Figure 3c–f shows that the perovskite films with TEA halides passivation exhibited relatively stable PL intensity within 10 min of continuous measurement, whereas the PL intensity of perovskite film without passivation drops to around a 60% of initial PL intensity. The results indicate that the radiative recombination of photogenerated electrons is favored rather than reacted with oxygen and formed superoxide radicals in the passivated films. Thus, the rate of superoxide radicals formation slows down. Although the diffusion of oxygen into perovskite films is inevitable, decrease of the ionic defects, especially anion defects, is a key to reducing the formation of superoxide radicals and to enhancing the stability of perovskite devices operation in air.

We quantitatively estimated the charge transfer dynamics of perovskite device by TRPL measurement. All the TRPL profiles are well fitted by the biexponential decay model as shown in Figure 3h. The equation of the biexponential model is shown below. It depicts two decay mechanisms of charge carrier behaviors including fast decay and slow decay processes. For PL lifetime analysis, all of the devices were prepared in the architecture of FTO glass/NiO/perovskite without or with passivation/PC61BM. Therefore, the fast decay of charge transfer process can be the result of the quenching of free carriers in the perovskite films through transport to hole transport layer (NiO) and electron transport layer (PC61BM). On the other hand, the slow decay process can be the result of radiative decay.\(^{45}\) As a result, the fast decay time \( (\tau_1) \) and its proportion coefficient \( (A_1) \) represent the charge transfer of perovskite film. The other is slow decay time \( (\tau_2) \) and its proportion coefficient \( (A_2) \), standing for the radiative recombination mechanism.\(^{46,47}\)

\[
I(t) = A_1 \exp\left(-\frac{t}{\tau_1}\right) + A_2 \exp\left(-\frac{t}{\tau_2}\right)
\]

The proportions of two decay mechanisms of charge carrier behaviors and charge transfer time of each device can be evaluated by the fractions of their proportion coefficient. For instance, the fraction of \( \frac{A_1}{(A_1 + A_2)} \) represents the ratio of charge transfer, whereas \( \frac{A_2}{(A_1 + A_2)} \) is the ratio of radiative recombination in the entire decay process. The calculated results are summarized in Table 4. With the assistance of electron transport layer (ETL) of PC61BM and hole transport layer (HTL) of NiO, both perovskite films with or without passivation exhibit high proportion of charge transfer compared with the radiative recombination. The TRPL profiles of perovskite with TEACl show the steepest exponential profiles in the series and demonstrate the highest charge transfer proportion of decay.

<table>
<thead>
<tr>
<th>sample</th>
<th>( \tau_1 ) (ns)</th>
<th>( A_1/(A_1 + A_2) ) (%)</th>
</tr>
</thead>
<tbody>
<tr>
<td>W/O passivation</td>
<td>13.78</td>
<td>91.93</td>
</tr>
<tr>
<td>W/TEACl</td>
<td>3.15</td>
<td>99.99</td>
</tr>
<tr>
<td>W/TEABr</td>
<td>4.59</td>
<td>99.17</td>
</tr>
<tr>
<td>W/TEAI</td>
<td>6.73</td>
<td>95.95</td>
</tr>
</tbody>
</table>
mechanism with value more than 99%. The PL intensity in Figure 3g is consistent with the trend of charge transfer proportion. Moreover, the perovskite film with TEACl passivation exhibits the fastest charge transfer as compared with perovskite films without passivation or with other passivation molecules. The small anion of Cl$^-$ with strong electron affinity and favorable band bending facilitates the electron transfer. Therefore, the presence of Cl$^-$ at the interface between perovskite and PC$_{61}$BM, promotes the fastest charge transfer rate. The results confirm that through the passivation, the charge carrier can be transferred and extracted to respective electrodes efficiently once they are created.

To gain insights into mobility and trapped density in the perovskite films with and without passivation, measurements for space-charge limited current (SCLC) model were performed. Figure 4a and Figure 4c show the $I$–$V$ curves of the electron-only and hole-only devices of perovskite films, respectively. In the $I$–$V$ curve, it can be divided into three regions that are the ohmic region ($I \propto V$), trap-filled limit region (TFL region, $I \propto V^n$, $n > 2$), and Child’s region ($I \propto V^2$). For the ohmic region and TFL region, the transition point between these two regions is known as trap filled limit voltage ($V_{TFL}$) according to the following equation:

$$V_{TFL} = \frac{eN_d d^2}{2\varepsilon\varepsilon_0}$$

Here, $e$ represents the elementary charge, $\varepsilon$ and $\varepsilon_0$ are the dielectric constant of perovskite and the permittivity of free space, $N_d$ is the trapped density of the thin film, and $d$ is the thickness of perovskite films. The calculated $N_d$ values from electron-only devices are $1.41 \times 10^{16}$, $3.33 \times 10^{15}$, $6.94 \times 10^{15}$,
and $5.92 \times 10^{15}$ (carrier number/cm$^3$), whereas for hole-only devices, the calculated $N_h$ are $3.88 \times 10^{16}$, $1.70 \times 10^{16}$, $2.84 \times 10^{16}$, $2.85 \times 10^{16}$, and $2.84 \times 10^{16}$ for perovskite films without passivation and with TEACl, TEABr, and TEAI passivation, respectively. It implies that fewer trapped states were present in the perovskite films with passivation than perovskite film without passivation for both electron-only and hole-only devices. The results prove that the TEA halides of dipolar ion passivation could compensate both types of ionic defects simultaneously and thus decrease the trap density of perovskite. In the Child’s region (high applied voltage region), the carrier mobility ($\mu$) can be derived from the following Mott–Gurney law:49

$$J = \frac{9e\varepsilon_r\mu V^2}{8d^5}$$

The electron mobility ($\mu_e$) can be obtained from Figure 4b, and the hole mobility ($\mu_h$) can be obtained from Figure 4d. The results are summarized in Table 5 and show that the post-

<table>
<thead>
<tr>
<th>Sample</th>
<th>Electron mobility (cm$^2$/V·s)</th>
<th>Hole mobility (cm$^2$/V·s)</th>
</tr>
</thead>
<tbody>
<tr>
<td>W/O passivation</td>
<td>1.96</td>
<td>0.40</td>
</tr>
<tr>
<td>W/TEACl</td>
<td>4.61</td>
<td>1.30</td>
</tr>
<tr>
<td>W/TEABr</td>
<td>3.44</td>
<td>1.12</td>
</tr>
<tr>
<td>W/TEAI</td>
<td>3.37</td>
<td>0.68</td>
</tr>
</tbody>
</table>

treatment of dipolar ion of TEA halides enhances electron and hole mobility from delicated passivation of ionic defects. The presence of Cl$^-$ helps perovskite band bending (vide infra) and provides an efficient path for electron injection to electron transport layer. Thus, after passivation with TEACl, the Cl$^-$ facilitates the electron extraction from perovskite to electron transport layer and exhibits the most significant enhancement of electron mobility.

Besides the intrinsic properties of perovskite, the interfacial resistance between perovskite and electron transport layer affects the performance of the device. The electrochemical impedance spectroscopy (EIS) of the device was carried out with applied bias near $V_{oc}$ (1.05 V) under illumination to estimate the interface resistance ($R_{interface}$). Figure 4 shows the Nyquist plots of perovskite solar cell without and with passivation (e), devices structure (f), and equivalent circuit (g). The elements of the equivalent circuit include the series resistance of device ($R_{series}$), interfacial resistance ($R_{interface}$), and the recombination resistance of perovskite ($R_{recombination}$).51

With the same hole transport layer and perovskite thickness, the $R_{interface}$ differences can be attributed to the passivation effects. From the model fitting of the equivalent circuit, the $R_{interface}$ between perovskite and electron transport layer can be calculated. The $R_{interface}$ of perovskite is around 45.6, 34.2, 34.5, 42.4 Ω for perovskite without passivation and with the passivation of TEACl, TEABr, and TEAI, respectively. Here, the TEACl passivation shows the lowest $R_{interface}$ of 34.2 Ω, which is in line with the result of high photovoltaic performance. For a brief summary, the devices with TEACl exhibit the best photovoltaic performance among devices (Supporting Information Figure S3). The anion effect of passivation molecules influences both transportation and mobility of charge carriers. The smallest size and strongest electron affinity of Cl$^-$ among three TEA halides help to passivate the vacancy and extract electrons to electron transport layer effectively.

To understand the characteristics of charge recombination process between devices with and without TEACl passivation, the light dependent (from 1 to 100 mV/cm$^2$) photovoltaic performance was carried out and shown in Figure 5a and Figure 5b. According to the Langevin theory, the charge recombination mechanism can be depicted by the slope of the semilogarithmic plot of $V_{oc}$ versus light intensity. The equation is expressed as the following:

$$V_i = V_i + \frac{n k_B T}{q} \ln \left( \frac{P_l}{P_i} \right)$$

Here, the $V_i$ represents $V_{oc}$ depending on light intensity; the $V_i$ is $V_{oc}$ under 100 mW/cm$^2$; the $k_B$ is Boltzmann constant; $T$ refers absolute temperature of 298 K; $q$ is the elementary charge, and the $P_l$ and $P_i$ are light intensity at different wavelength and standard sunlight intensity (100 mW/cm$^2$), respectively. The ideality factor ($n$) reveals the dominant type of recombination behaviors of devices, where ideality factor $n = 1$ indicates the bimolecular recombination and $n = 2$ represents the trap-assisted recombination.54 In Figure 5b, compared with devices without passivation ($n = 1.77$), the trap-assisted recombination in devices can be significantly suppressed using TEACl passivation ($n = 1.43$) due to the reduced trap density in perovskite films.

Figure 5. Dependent performance of devices without and with TEACl passivation on light intensity: (a) short-circuit current ($J_{sc}$) and (b) open-circuit voltage ($V_{oc}$).
To observe the morphology of perovskite thin films and their charge transfer behaviors, the measurements of atomic force microscopy and Kelvin-probe atomic force microscopy were conducted. The topography is very similar for pristine perovskite film (Figure 6a-1), and the perovskite film with TEACl passivation (Figure 6 b-1). Both films were deposited on the hole transport layer. The grain sizes of both perovskite films are in hundred nanometer scale. The surface potential mapping of the perovskite with TEACl passivation in the dark are shown in Figure 6a-2 and Figure 6b-2 and under illumination in Figure 6a-3 and Figure 6b-3. The locations of surface potential mapping on the samples were fixed to observe the changes of surface potential from in dark to under illumination. The distribution of surface potential is very smooth for the film without passivation (∼−200 mV to 200 mV) as compared with the film without passivation (∼−400 mV to −100 mV). The change of surface potential is very minor from in dark to under illumination for the perovskite film with TEACl as compared with the film without it, which can be attributed to the slight band bending effect from the passivation. The dark spots with low surface potential indicate the grain boundaries and defects of the films as shown in Figure 6a-1 and Figure 6b-1. The grain boundaries and defects of the film trap carriers easily and therefore cause large change in surface potential under illumination. Apparently, the film without passivation contained many defects and boundaries and trapped carriers, whereas the TEACl passivation can reduce defects and suppress the carrier trapping.

Figure 6. Surface characteristics of perovskite films without and with TEACl passivation: (a-1, b-1) topography mapping and (a-2, b-2) surface potential mapping in the dark; (a-3, b-3) under illumination (scale bar = 1 μm).

The maximum power point tracking of devices without encapsulation in ambient air directly indicate whether the photovoltaic performance of devices is stable in the presence of moisture and light. Generally, the presence of moisture, oxygen, and light is believed to gradually degrade the perovskite layer and therefore deteriorate the device performance. Reducing ionic defects in perovskite film can prevent it from the fast oxygen diffusion and thus improve the stability of devices. Figure 7a shows the cross-sectional SEM images of perovskite devices. The configurations of devices fabricated from the perovskite film with and without TEACl passivation can be clearly observed. There are no differences in the layer structure and thickness for two devices. The thickness of each layer can be identified (NiO is around 100 nm; CH3NH3PbI3 is 450 nm; PC61BM is 90 nm; Ag electron is 100 nm). The SEM images of other devices are shown in Figure S4. Figure 7b–e shows the photovoltaic distribution of 24 devices fabricated from the perovskite film with and without TEACl passivation. The results show high reproducibility of TEACl passivated devices. The average PCE of devices having TEACl passivation can be enhanced from 14.62% to 17.78%. Furthermore, the PCE of the champion device having TEACl passivation can be enhanced from the original 15.44% to 18.84% with no hysteresis as shown in Figure 7f. The outstanding PCE improvement is attributed to the increase of Voc and fill factor. From the systematic analysis of perovskite with TEACl passivation, we demonstrate that ionic defects in perovskite film are successfully passivated and the nonradiative recombinations of charge carriers are reduced as well. The reduction of energy loss directly reflected by the enhancement of Voc and PCE of the devices.

Figure 7g shows the 300 s maximum power point track (MPPT) of devices fabricated from perovskite film with and without TEACl passivation in air (relative humidity = 65%, operating temperature of devices = 50 °C). The devices were not encapsulated. Prior to the MPPT measurement of devices, the J–V curves were measured to determine the optimal applied voltage of MPPT. The devices having TEACl passivation exhibit an extremely stable output with less than 0.1% PCE drop after 300 s measurement. The PCE can still maintain over 18.6% after 300 s measurement. However, the devices without passivation were vulnerable in air, and the irreversible PCE drop was larger than 8% from initial PCE of device. It clearly indicates that the deteriorated performance of device without passivation is more susceptible to heat and humidity than the device with TEACl passivation. For the intrinsic stability of perovskite, the device with and without passivation was stored in the same environment of nitrogen. As Figure 7h shows, the device without passivation can only maintain 80% of initial PCE in the first 400 h, whereas the device with TEACl passivation can maintain 80% of initial PCE over 700 h. It again provides evidence that the suppressed ionic defects in perovskite can prevent devices from defect assisted degradation.
4. CONCLUSIONS

We systematically explored the passivation of ionic defects of hot casted perovskite film using various dipolar ions of organo-ammonium halide: MAI, PEAI, TEA halides. The dipolar ions can passivate both cationic and anionic defects simultaneously.

Spectroscopy, electronic, and device characterizations were performed to investigate the TEA halides passivation effect. With the significant decrease of ionic defect density in perovskite and successful interfacial modification, the nonradiative recombination can be efficiently reduced and thereby enhance the open-circuit voltage and fill factor of the devices. The TEACl...
is the most effective one because of its high ionization constant and small anion. The power conversion efficiency of planar p-i-n devices with TEACl passivation shows improved PCE from 15.44% to 18.89% as compared to perovskite solar cell without passivation. The results of maximum power output tracking of devices also demonstrate outstanding stability of devices with TEACl passivation. This facile surface passivation strategy is promising for preparing high quality stable perovskite solar cells using conventional upscale coating technology that paves the way for commercialization.

■ ASSOCIATED CONTENT

Notes

Wei-Fang Su: 0000-0002-3375-4664
Ming-Chung Wu: 0000-0002-3584-3871
*Corresponding Author

AUTHOR INFORMATION

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsaem.9b00486.

Photography of perovskite films treated with various solvent and diopar ions in IPA and their XRD patterns, grazing-incidence wide-angle X-ray scattering (GIWAXS) spectra, performance distribution of devices, cross-sectional image from FE-SEM, and table of device PCE (PDF)

Article

ACS Applied Energy Materials

is the most effective one because of its high ionization constant and small anion. The power conversion efficiency of planar p-i-n devices with TEACl passivation shows improved PCE from 15.44% to 18.89% as compared to perovskite solar cell without passivation. The results of maximum power output tracking of devices also demonstrate outstanding stability of devices with TEACl passivation. This facile surface passivation strategy is promising for preparing high quality stable perovskite solar cells using conventional upscale coating technology that paves the way for commercialization.

■ ASSOCIATED CONTENT

Notes

Wei-Fang Su: 0000-0002-3375-4664
Ming-Chung Wu: 0000-0002-3584-3871
*Corresponding Author

AUTHOR INFORMATION

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsaem.9b00486.

Photography of perovskite films treated with various solvent and diopar ions in IPA and their XRD patterns, grazing-incidence wide-angle X-ray scattering (GIWAXS) spectra, performance distribution of devices, cross-sectional image from FE-SEM, and table of device PCE (PDF)

Article

ACS Applied Energy Materials

is the most effective one because of its high ionization constant and small anion. The power conversion efficiency of planar p-i-n devices with TEACl passivation shows improved PCE from 15.44% to 18.89% as compared to perovskite solar cell without passivation. The results of maximum power output tracking of devices also demonstrate outstanding stability of devices with TEACl passivation. This facile surface passivation strategy is promising for preparing high quality stable perovskite solar cells using conventional upscale coating technology that paves the way for commercialization.

■ ASSOCIATED CONTENT

Notes

Wei-Fang Su: 0000-0002-3375-4664
Ming-Chung Wu: 0000-0002-3584-3871
*Corresponding Author

AUTHOR INFORMATION

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsaem.9b00486.

Photography of perovskite films treated with various solvent and diopar ions in IPA and their XRD patterns, grazing-incidence wide-angle X-ray scattering (GIWAXS) spectra, performance distribution of devices, cross-sectional image from FE-SEM, and table of device PCE (PDF)

Article

ACS Applied Energy Materials

is the most effective one because of its high ionization constant and small anion. The power conversion efficiency of planar p-i-n devices with TEACl passivation shows improved PCE from 15.44% to 18.89% as compared to perovskite solar cell without passivation. The results of maximum power output tracking of devices also demonstrate outstanding stability of devices with TEACl passivation. This facile surface passivation strategy is promising for preparing high quality stable perovskite solar cells using conventional upscale coating technology that paves the way for commercialization.

■ ASSOCIATED CONTENT

Notes

Wei-Fang Su: 0000-0002-3375-4664
Ming-Chung Wu: 0000-0002-3584-3871
*Corresponding Author

AUTHOR INFORMATION

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsaem.9b00486.

Photography of perovskite films treated with various solvent and diopar ions in IPA and their XRD patterns, grazing-incidence wide-angle X-ray scattering (GIWAXS) spectra, performance distribution of devices, cross-sectional image from FE-SEM, and table of device PCE (PDF)

Article

ACS Applied Energy Materials

is the most effective one because of its high ionization constant and small anion. The power conversion efficiency of planar p-i-n devices with TEACl passivation shows improved PCE from 15.44% to 18.89% as compared to perovskite solar cell without passivation. The results of maximum power output tracking of devices also demonstrate outstanding stability of devices with TEACl passivation. This facile surface passivation strategy is promising for preparing high quality stable perovskite solar cells using conventional upscale coating technology that paves the way for commercialization.

■ ASSOCIATED CONTENT

Notes

Wei-Fang Su: 0000-0002-3375-4664
Ming-Chung Wu: 0000-0002-3584-3871
*Corresponding Author

AUTHOR INFORMATION

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsaem.9b00486.

Photography of perovskite films treated with various solvent and diopar ions in IPA and their XRD patterns, grazing-incidence wide-angle X-ray scattering (GIWAXS) spectra, performance distribution of devices, cross-sectional image from FE-SEM, and table of device PCE (PDF)

Article

ACS Applied Energy Materials

is the most effective one because of its high ionization constant and small anion. The power conversion efficiency of planar p-i-n devices with TEACl passivation shows improved PCE from 15.44% to 18.89% as compared to perovskite solar cell without passivation. The results of maximum power output tracking of devices also demonstrate outstanding stability of devices with TEACl passivation. This facile surface passivation strategy is promising for preparing high quality stable perovskite solar cells using conventional upscale coating technology that paves the way for commercialization.

■ ASSOCIATED CONTENT

Notes

Wei-Fang Su: 0000-0002-3375-4664
Ming-Chung Wu: 0000-0002-3584-3871
*Corresponding Author

AUTHOR INFORMATION

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsaem.9b00486.

Photography of perovskite films treated with various solvent and diopar ions in IPA and their XRD patterns, grazing-incidence wide-angle X-ray scattering (GIWAXS) spectra, performance distribution of devices, cross-sectional image from FE-SEM, and table of device PCE (PDF)

Article

ACS Applied Energy Materials

is the most effective one because of its high ionization constant and small anion. The power conversion efficiency of planar p-i-n devices with TEACl passivation shows improved PCE from 15.44% to 18.89% as compared to perovskite solar cell without passivation. The results of maximum power output tracking of devices also demonstrate outstanding stability of devices with TEACl passivation. This facile surface passivation strategy is promising for preparing high quality stable perovskite solar cells using conventional upscale coating technology that paves the way for commercialization.

■ ASSOCIATED CONTENT

Notes

Wei-Fang Su: 0000-0002-3375-4664
Ming-Chung Wu: 0000-0002-3584-3871
*Corresponding Author

AUTHOR INFORMATION

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsaem.9b00486.

Photography of perovskite films treated with various solvent and diopar ions in IPA and their XRD patterns, grazing-incidence wide-angle X-ray scattering (GIWAXS) spectra, performance distribution of devices, cross-sectional image from FE-SEM, and table of device PCE (PDF)

Article

ACS Applied Energy Materials

is the most effective one because of its high ionization constant and small anion. The power conversion efficiency of planar p-i-n devices with TEACl passivation shows improved PCE from 15.44% to 18.89% as compared to perovskite solar cell without passivation. The results of maximum power output tracking of devices also demonstrate outstanding stability of devices with TEACl passivation. This facile surface passivation strategy is promising for preparing high quality stable perovskite solar cells using conventional upscale coating technology that paves the way for commercialization.

■ ASSOCIATED CONTENT

Notes

Wei-Fang Su: 0000-0002-3375-4664
Ming-Chung Wu: 0000-0002-3584-3871
*Corresponding Author

AUTHOR INFORMATION

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsaem.9b00486.